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Applicant:

Daniel F. Downey et al.

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ATHERMAL ANNEALING WITH RAPID THERMAL

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Examiner:

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## **CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)**

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Sir:

Transmitted herewith are the following documents:

[X] Final Amendment

[X] Request for Continued Examination

[X] Petition for Three Month Extension of Time

[X] Return Receipt Postcard

If any fees are determined to be required or if there are any overpayments, Deposit Account 50-0896 may be charged or credited.

Respectfully submitted,

Daniel F. Downey et al., Applicants

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